In the Claims

Please amend the claims as follows.

Kindly cancel claims 18-25, without prejudice.

1. (Original) A carrier for a semiconductor die comprising:

a substrate having a cavity formed in said substrate, said cavity having a bottom and sidewalls, said sidewalls having a stepped tier;

a plurality of electrically conductive contacts on an underside of said substrate;

a plurality of electrically conductive tabs disposed on said stepped tier;

a plurality of electrically conductive external bond terminals disposed on an edge of said substrate; and

a plurality of electrically conductive paths formed in said substrate and electrically coupled between said electrically conductive tabs, said electrically conductive contacts, and said electrically conductive external bond terminals.

- 2. (Original) A carrier for a semiconductor die as in claim 1, wherein said substrate is formed from a multilayer of ceramic substrates.
- 3. (Original) A carrier for a semiconductor die as in claim 1, wherein said substrate is formed from laminates of organic dielectrics.
- 4. (Original) A carrier for a semiconductor die as in claim 1, wherein said substrate is formed from deposited thin film layers.

- 5. (Original) A carrier for a semiconductor die as in claim 1 further including a sealing lid disposed on said substrate and covering said cavity.
- 6. (Original) A carrier for a semiconductor die as in claim 1 further including a plurality of wires electrically coupled between the semiconductor die and the plurality of electrically conductive tabs.
- 7. (Original) A carrier for a semiconductor die as in claim 1 wherein said plurality of electrically conductive external bond terminals disposed on an edge of said substrate are disposed on a ledge in a recess formed in said edge of said substrate.
- 8. (Original) A carrier for a semiconductor die as in claim 1 wherein said plurality of electrically conductive paths are formed from conductive vias and conductive lines in said substrate.
- 9. (Original) A carrier for a semiconductor die as in claim 1 wherein said sidewalls have a plurality of stepped tiers and said plurality of electrically conductive tabs are disposed on said plurality of stepped tiers.
 - 10. (Original) A carrier for a semiconductor die comprising: a substrate having an upper surface and a lower surface;
- a plurality of electrically conductive surface contacts disposed on said upper surface of said substrate;
- a plurality of electrically conductive contacts on an underside of said substrate;

a plurality of electrically conductive external bond terminals disposed on an edge of said substrate; and

a plurality of electrically conductive paths formed in said substrate and electrically coupled between said electrically conductive surface contacts, said electrically conductive contacts, and said electrically conductive external bond terminals.

- 11. (Original) A carrier for a semiconductor die as in claim 10, wherein said substrate is formed from a multilayer of ceramic substrates.
- 12. (Original) A carrier for a semiconductor die as in claim 10, wherein said substrate is formed from laminates of organic dielectrics.
- 13. (Original) A carrier for a semiconductor die as in claim 10, wherein said substrate is formed from deposited thin film layers.
- 14. (Original) A carrier for a semiconductor die as in claim 10 further including a cover disposed on said substrate and covering the semiconductor die.
- 15. (Original) A carrier for a semiconductor die as in claim 10 wherein the semiconductor die has a plurality of semiconductor die contacts electrically connected to said plurality of electrically conductive surface contacts.

- 16. (Original) A carrier for a semiconductor die as in claim 10 wherein said plurality of electrically conductive external bond terminals disposed on an edge of said substrate are disposed on a ledge in a recess formed in said edge of said substrate.
- 17. (Original) A carrier for a semiconductor die as in claim 10 wherein said plurality of electrically conductive paths are formed from conductive vias and conductive lines in said substrate.
 - 18. (Canceled)
 - 19. Canceled)
 - 20. (Canceled)
 - 21. (Canceled)
 - 22. (Canceled)
 - 23. (Canceled)
 - 24. (Canceled)
 - 25. (Canceled)